# Nanoscopy

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#### SoSe 2015



#### SIM reconstruction algorithm

- Image formation in SIM
- Fourier space decomposition
- Measurement with structured illumination
- Illumination in Fourier space
- Illumination parameter estimation
- Fourier space shifts and separation

### 2 Summary and Outlook

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Sorry, some math...

$$\frac{\partial \Theta}{\partial \theta} MT(\xi) = \frac{\partial}{\partial \theta} \int_{R_{n}}^{T} T(x) f(x, \theta) dx = \int_{R_{n}}^{1} \frac{\partial}{\partial \theta} \int_{R_{n}}^{1}$$

Math (from here)

### Image formation in SIM

$$M_{l}(x,y) = \int_{S_{z}} \mathsf{PSF}(x,y,z) * (l_{l}(x,y,z) \cdot S(x,y,z)) \,\mathrm{d}z \tag{1}$$
$$l(x,y,z) = \mathsf{PSF}_{\mathsf{ex.}}(x,y,z) * l'(x,y,z) \tag{2}$$

- Interested in: Sample response (fluorescence density) S(x, y, z).
- Limited by: PSF, i.e. Abbe limit lateral, background axial
- All SIM approaches:
  - Obtain S(x, y, z)
  - by combining multiple measurements M<sub>I</sub>
  - for different illuminations  $I_i(x, y, z)$
- Keep in mind: Illumination also limited by PSF<sub>ex.</sub>.

# Solve for S(x, y, z)

$$M_{l}(x,y) = \int_{S_{z}} \mathsf{PSF}(x,y,z) * (l_{l}(x,y,z) \cdot S(x,y,z)) \, \mathrm{d}z \tag{3}$$
$$l(x,y,z) = \mathsf{PSF}_{\mathsf{ex.}}(x,y,z) * l'(x,y,z) \tag{4}$$

- Convolution integral: No direct solution for S(x, y, z)
- Iterative solvers possible, but that is more advanced
- Direct solution
  - possible for specific forms of  $l_1(x, y, z)$
  - by decomposition in Fourier space



#### Decomposition in Fourier space

$$\tilde{M}_{l}(k_{x,y}) = \int_{S_{z}} \mathsf{OTF}(k_{x,y,z}) \cdot \left(\tilde{l}_{l}(k_{x,y,z}) * \tilde{S}(k_{x,y,z})\right) dz$$
(5)  
$$\tilde{l}(k_{x,y,z}) = \mathsf{OTF}_{\mathsf{ex.}}(k_{x,y,z}) \cdot \tilde{l}'(k_{x,y,z})$$
(6)

- In Fourier space:  $I(k_{x,y,z})$  folds with  $S(k_{x,y,z})$
- Assume  $l(k_{x,y,z}) = \sum_i \delta_i(k_{x,y,z})$
- Then  $M_l$  given by
  - Finite sum of shifted copies of S(k<sub>x,y,z</sub>)
  - Each shift position given by  $k_{x,y,z}$  in  $\delta_i(k_{x,y,z})$
- Collect as many  $M_i$  as there are  $\delta_i(k_{x,y,z})$ 
  - $\rightarrow$  directly solvable for  $S(k_{x,y,z})$
- 2D SIM: 2 peaks from sin, 1 peak from DC

## Step 1: Measurement for structured illumination

### Regular illumination pattern

Use

$$I_l(x,y) = \frac{I_0}{2} \cdot \left[1 + \sin((2\pi \cdot p + \phi)/\kappa)\right]$$

where

$$p = x \cdot \cos(\alpha) + y \cdot \sin(\alpha)$$

#### Multiple measurements

- Use multiple angles α for illumination Typically 3 or 4, evenly spaced
- For each angle, illuminate with (at least) 3 phases  $\phi = \frac{0}{3}\pi, \frac{2}{3}\pi, \frac{4}{3}\pi$ 
  - Phases not evenly spaced: loss of SNR
  - More than three phases: Reconstruction gets over-defined, but still possible
- Number of angles: Full resolution enhancement along each angle  $\alpha$ .

## Step 1: Illumination pattern



Left: First illumination pattern. Right: Montage of all illumination patterns



# Step 1: Measurement (2D SIM)

Test surface dye-filled beads. Pattern spacing: 256 nm ( $\sim 86\%$  of resolution limit).





Left: First illumination pattern. Right: Cut-out, montage of all patterns Any visible variation between the different patterns?



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# Step 1: Measurement (2D TIRF SIM)

Test surface dye-filled beads. Pattern spacing:  $256 \ \mathrm{nm}$  (at resolution limit).





Left: First illumination pattern. Right: Cut-out, montage with spectrum LUT Look closely at the bright structures...



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# Step 2: Illumination in Fourier space

$$I_l(x,y) = \frac{I_0}{2} \cdot \left[1 + \sin((2\pi \cdot p + \phi)/\kappa)\right]$$

where

$$p = x \cdot \cos(\alpha) + y \cdot \sin(\alpha)$$



Left: Illumination pattern. Right: FFT / FHT power spectrum

Three dots in FFT

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## Step 2: Illumination in Fourier space

$$ilde{\mathcal{M}}_{l}(k_{x},k_{y})=\mathsf{OTF}\cdot\left( ilde{\mathcal{S}}(k_{x},k_{y})* ilde{l}_{l}(k_{x},k_{y})
ight)$$

Test surface



 $\label{eq:left_limit} \begin{array}{l} \mbox{Left: Illumination pattern. Right: FFT / FHT power spectrum} \\ Fourier space reveals the illumination pattern^1. \end{array}$ 

 $^1 \rm but$  only because  $\kappa \sim 0.8 \kappa_{\rm max}$ 

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# Step 2: Acquire parameters

- Three peaks in FFT power spectrum: Center "DC" and symmetric  $sin(2\pi \cdot p + \phi)$ -contribution.
- Position directly translates to κ, α.
- The phase φ is contained in z = r · e<sup>iφ</sup>, as the FFT yields a complex number. However, it is easily distorted by other structures in the sample.





## Step 3: Decompose the measurements

#### Measurement

Three phases  $\phi_0, \phi_1, \phi_2$  for illumination, each row in *K* represents one measurement:

$$\mathcal{K} = \begin{pmatrix} 1 & \frac{1}{2}e^{i\phi_0} & \frac{1}{2}e^{-i\phi_0} \\ 1 & \frac{1}{2}e^{i\phi_1} & \frac{1}{2}e^{-i\phi_1} \\ 1 & \frac{1}{2}e^{i\phi_2} & \frac{1}{2}e^{-i\phi_2} \end{pmatrix}$$

Columns: DC contributions, two symmetric contributions from the sinusoidal form.

#### Decomposition

Invert<sup>a</sup> K to  $K^{-1}$ . Via  $K^{-1}$ , get the DC contribution (wide-field) and higher frequencies.

 $a^{3} \times 3$  matrix, otherwise Moore-Penrose pseudo inverse





## Step 3: Spatial results of decomposition



DC component reconstructs to an images with wide-field characteristics. Sinusoidal components not yet meaningful, but:  $\kappa$  and  $\alpha$  have not been used so far.  $\bigcirc$   $\bigcirc$ 

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# Step 3: Shifting frequency components

#### Compute shift

- DC component: Widefield, done.
- Two symmetric components:  $sin((2\pi \cdot p + \phi)/\kappa)$ , where  $p = x \cdot cos(\alpha) + y \cdot sin(\alpha)$
- $\bullet\,$  Shift these contributions by  $\pm\kappa,\alpha$

### Result

- Pixels needed for shift: Resolution enhancement
- $+\kappa$  and  $-\kappa$ : contain the same information by definition
- Spatial transformation: Structure becomes apparent





### Step 3: Added frequency components



Add up the DC and shifted sinusoidal components. Result: Resolution-enhancement along illumination pattern direction  $\alpha$ .

# Interim result

- Sinusoidal pattern<sup>2</sup>, 3 contributions in Fourier space
- Matrix inversion, decomposition and shift
- Resolution enhancement along the pattern direction
- Number of phases: At least 3, more lead to an over-defined matrix
- $\bullet$  When measuring these 3 phases,  $\kappa$  and  $\alpha$  have to be fixed, phases should be evenly spaced.
- Number of angles: Arbitrary, but usually 3 or 4 to fill the Fourier space.
- $\kappa$  may change between angles  $\alpha$ .
- **Resolution enhancement:** Directly given by pattern spacing  $\kappa$ .



<sup>&</sup>lt;sup>2</sup>Other pattern: How does their Fourier transform look like?

### Step 4: Measure for multiple angles $\alpha$



Three angles  $\alpha$ . Resolution enhancement along each angle of the pattern. Next step: Combine these spectra.



Step 4: Combine all angles

$$\tilde{M}_{l}(k_{x},k_{y}) = \mathsf{OTF}(k_{x},k_{y}) \cdot \left(\tilde{S}_{l}(k_{x},k_{y}) * \tilde{I}(k_{x},k_{y})\right)$$



Low, high and all frequency components

Low frequency widefield, high frequency additional information, all frequencies combined. Close, but not quite right. What is missing?

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## Step 5: OTF frequency filtering

$$ilde{\mathcal{M}}_l(k_{\mathrm{x}},k_{\mathrm{y}}) = \mathsf{OTF} \cdot \left( ilde{\mathcal{S}}(k_{\mathrm{x}},k_{\mathrm{y}}) * ilde{l}_l(k_{\mathrm{x}},k_{\mathrm{y}})
ight)$$

- So far, result looks better, but not quite right
- Transfer function: Not only limits resolution, but dampens high frequencies
- This leads to problems when shifting components around
- Solution: Divide by OTF in frequency domain.
- However: Low to zero regions in OTF will cause artifacts
- Full solution: frequency filtering



Step 5: (modified/generalized) Wiener filter

$$\tilde{R}(k_{x}, k_{y}) = \sum_{l} \frac{OTF(k_{x}, k_{y})\tilde{M}_{l}(k_{x}, k_{y})}{OTF^{2}(k_{x}, k_{y}) + \omega}$$

- Multiply by OTF and divide by OTF<sup>2</sup>, thus: Result without frequency dampening
- Numerator: One contribution of OTF is multiplied in post-processing, one is inherent to the measurement.
- Parameter ω: Artificial high-frequency dampening.
   Dominates in regions of a low OTF, with quadratic response.
- Determining the OTF: Big difference between 2D and 3D: 2D: Use any OTF (Gaussian, Bessel, ...) with a somewhat matching FWHM 3D: Measure a quite exact OTF along the axial direction.
- There are more involved filtering methods available (e.g. iterative ones like total variations)

But: No further information is generated by filtering.

### Step 5: Result of Wiener filtering



Reconstruction with different Wiener filter settings:

0.05, 0.1, 0.5, 2, 10, 50

<u>@ 00</u>

### Step 5: Apotization

$$\tilde{S}'(k_x, k_y) = \mathsf{APO} \cdot \sum_l \frac{\mathsf{OTF}(k_x, k_y) \tilde{M}_l(k_x, k_y)}{\mathsf{OTF}^2(k_x, k_y) + \omega}$$

- After the filtering step,  $R(k_x, k_y)$  now has no "natural" dampening of higher frequencies.
- This leads to harsh contrasts that would not be obtained by a higher resolution microscope
- Fix: Multiply an apotization function APO to the result
- APO: An artificial OTF, dampening high frequency components the same way a microscope would
- FWHM of the APO: motivated by the higher resolution limit set through the original OTF,  $\kappa$  and (to a lesser degree)  $\omega$ .
- In practice: Start with FWHM<sub>APO</sub> =  $2 \cdot$  FWHM<sub>OTF</sub>, tweak  $\omega$  and APO with lots of leeway.

### Step 5: Final result



200 nm Tetraspeck beads, excitation at 643 nm, measured on a DeltaVision OMX (GE LifeScience), Wide-field [A], filtered wide-field [B], single slice 2D SIM-reconstruction by our software [C], 3D SIM reconstruction of the same slice, by SoftWORX (Applied Precision/GE LifeScience) [D].



Wide-field [A], filtered wide-field [B], single slice 2D SIM reconstruction by our software (C], 3D SIM reconstruction of the same slice, by SoftWORX (Applied Precision/GE LifeScience) [D]. LSEC actin filaments are labeled with AlexaFluor 488 / Phalloldin, measured on a DeltaVision OMX (GE LifeScience).



# Summary and Outlook

Algorithm presented today

- Sinusoidal form needed
- 2D since ≈ 2000, 3D since ≈ 2008.
- In Bielefeld: OMX and self-made setup
- In development: Free, open-source reconstruction software

#### Outlook next lectures

- SIM: Extension to 3D
- SIM: Iterative solvers
- Localization microscopy

